

WEST Search History

DATE: Tuesday, August 26, 2003

<u>Set Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
		result set	
<i>DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
L19	microwave annealing.ti.	13	L19
L18	L15 and magnetic field	5	L18
L17	L15 and thermal heat\$3	1	L17
L16	L15 and thermal heat	0	L16
L15	L14 and semiconductor	135	L15
L14	low temperature with RTA	148	L14
L13	L9 and thermal heat\$	3	L13
L12	L4 and magnetic field	85	L12
L11	L8 and magnetic field	3	L11
L10	L9 and magnetic field	3	L10
L9	L8 and semiconductor	133	L9
L8	low temperature rapid thermal anneal\$3	177	L8
L7	L4 and induction	45	L7
L6	L4 and (anneal\$3).ti.	27	L6
L5	L4 and (RTA with (low temperature))	23	L5
L4	L3 and implant\$5	649	L4
L3	L1 and (low temperature)	1046	L3
L2	L1 and LTRTA	0	L2
L1	semiconductor and (RTA or RTP or rapid thermal) and lamp\$1	2568	L1

END OF SEARCH HISTORY

For 09/996 446